

What is new in V4.0

- 新的介质层简化 (MergeThinLayer) 方式, 适应性更强, 更加稳定。
- 支持使用Sheet层简化薄层, 比如0.001um的金属层。
- 增加Layers自动对齐功能, 避免叠层运算引入的Small Gap, 导致网格生成问题。
- 引入配置文件, 用户可以自定义设定值, 部分UI没有展现的字段可以通过配置文件修改。
- 修复了在V3.0反馈的小bug。

MergeThinLayer

GDSII Import Wizard V4.0

Step1: TechnologyFile Input Step2: Extract Netlist Step3: Stackup XML Step4: Generate EBD

Switch to Proficiency Mode

Generate Stackup XML

Stackup XML

☒ SimplifyDielectric ☐ CreateViaGroups ☐ LegacyXml(Laminate)

☒ NoMergeTSVLayer ☒ UseSheetLayer

☐ UseDefaultDF

新的介质合并方法“MergeThinLayer”：

- 1) 可以指定IRCX介质厚度小于某个数值时，和相邻层合并。默认值0.1um
- 2) 可以指定2个相邻介质层的DK插值小于xx百分比时，进行合并。默认值10%

设置发生合并的阈值

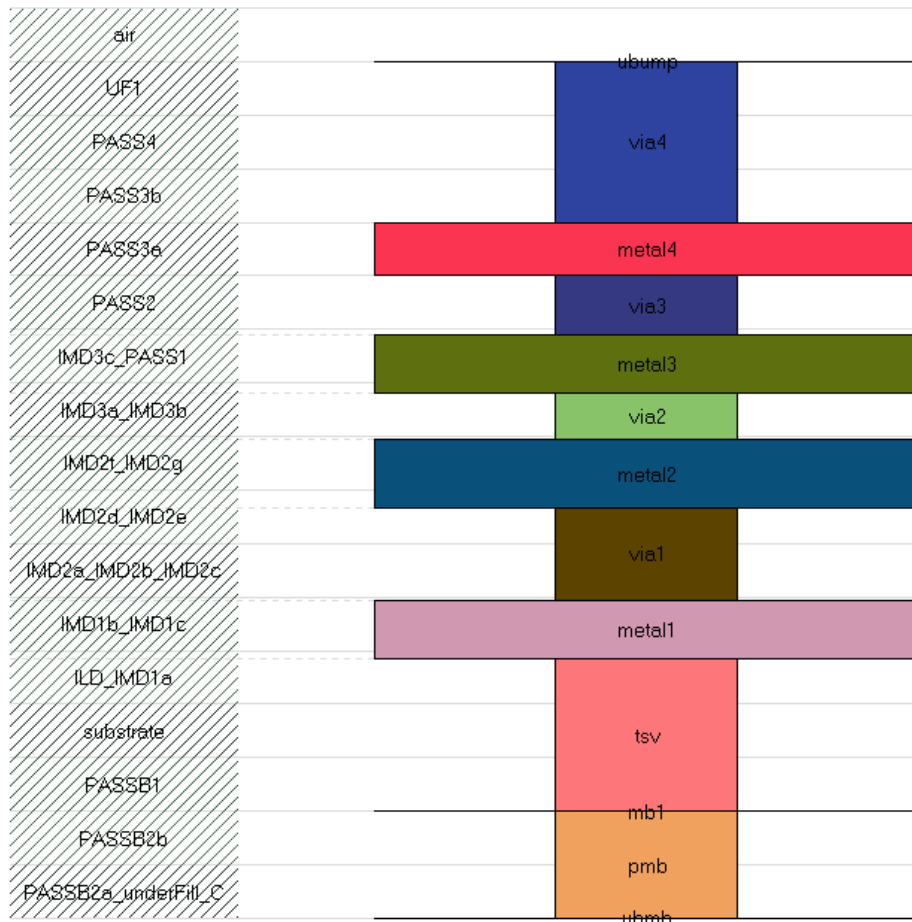
MergeThinLayer

* DIELECTRIC 25 11 (NAME:V, TYPE:V, HEIGHT:V, THICKNESS:V, FIELD					
NAME	TYPE	HEIGHT	THICKNESS	CONSTANT	
UF1	D	107.640000	35.000000	3.70	N/A
PASS4	P	107.040000	0.600000	8.10	N/A
PASS3b	P	106.640000	0.400000	4.20	N/A
PASS3a	P	105.190000	1.450000	4.20	N/A
PASS2	P	104.490000	0.700000	4.20	N/A
PASS1	P	104.415000	0.075000	8.10	N/A
IMD3c	D	103.690000	0.725000	4.20	N/A
IMD3b	D	103.640000	0.050000	8.10	N/A
IMD3a	D	103.020000	0.620000	4.20	N/A
IMD2g	D	102.970000	0.050000	5.00	N/A
IMD2f	D	102.245000	0.725000	4.20	N/A
IMD2e	D	102.195000	0.050000	8.10	N/A
IMD2d	D	101.873000	0.322000	4.20	N/A
IMD2c	D	101.793000	0.080000	4.20	N/A
IMD2b	D	101.775000	0.018000	4.20	N/A
IMD2a	D	101.575000	0.200000	4.20	N/A
IMD1c	D	101.525000	0.050000	5.00	N/A
IMD1b	D	100.800000	0.725000	4.20	N/A
IMD1a	D	100.750000	0.050000	8.10	N/A
ILD	D	100.000000	0.750000	4.00	N/A
substrate	D	0.000000	100.000000	11.90	N/A
PASSB1	P	-0.800000	0.800000	6.70	N/A
PASSB2b	P	-2.800000	2.000000	6.70	N/A
PASSB2a	P	-3.200000	0.400000	6.70	N/A
underFill_C	D	-3.201000	0.001000	6.70	N/A

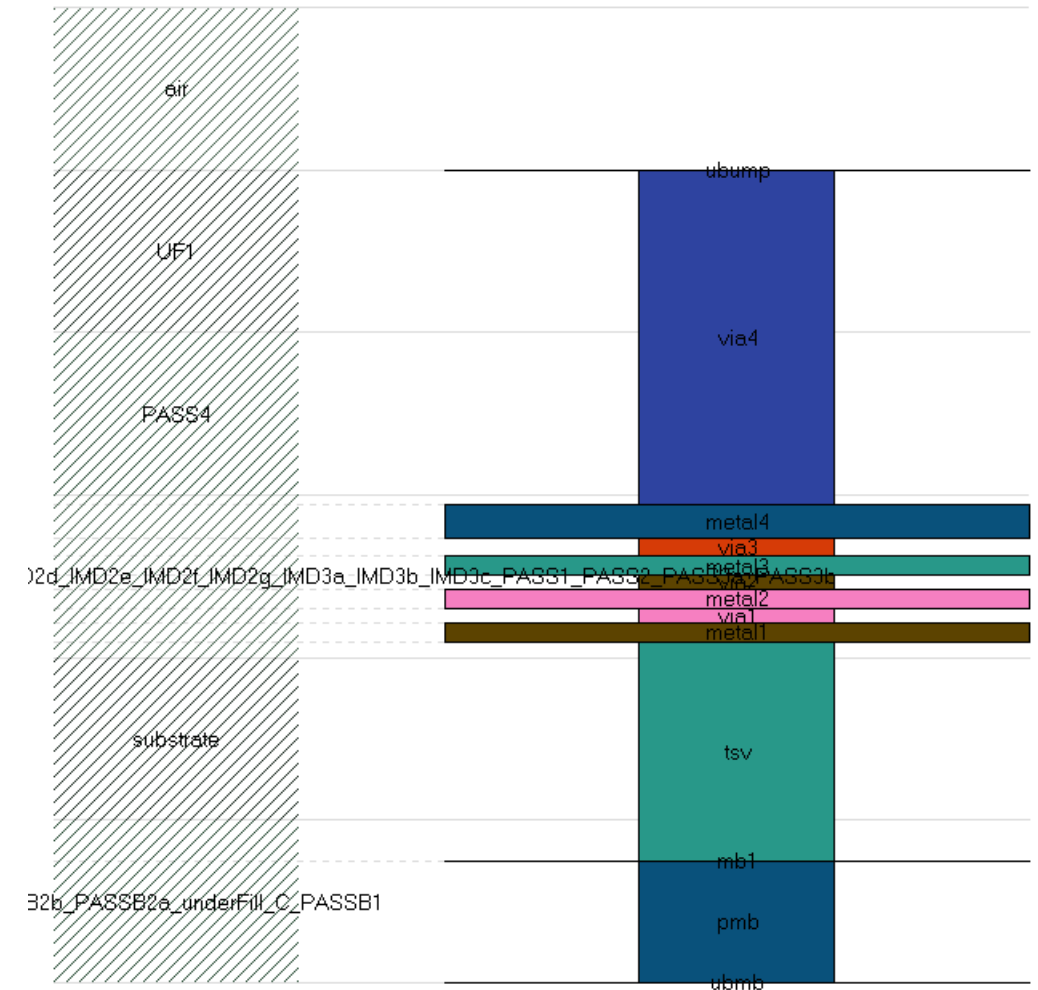
Thickness < 0.1 μm , 合并到相邻层
优先合并到DK值接近的相邻层
DK值会按照选定的方法进行平均运算。

DK值一致, 发生合并

MergeThinLayer



thinDielectricThreshold = 0.1
dkDeviationThreshold = -1



thinDielectricThreshold = 0.1
dkDeviationThreshold = 0.1

/ UseSheetLayer

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Generate Stackup XML

Stackup XML

SimplifyDielectric MergeThinLayer ☒ CreateViaGroups ☐ LegacyXml(Laminate)

MergeMethod Weighted Average ☒ NoMergeTSVLayer ☒ UseSheetLayer




ThinDielectricThreshold ☐ UseDefaultDF

ThinDielectricThreshold

勾选UseSheetLayer，工具会把0.001um的层转成Sheet(0um)，减小网格的生成。
工具会对层位置进行对齐，避免转换后带来的Gap。

Configuration字段配置 (JSON文件)

首次运行，会在工具目录下生成gds2xml.json配置文件，通过修改配置文件中的字段，可以修改工具的默认配置。

名称	修改日期	类型	大小
 gds2xml.json	5/25/2021 9:16 pm	JSON File	1 KB
 GDSImportWizard.py	5/21/2021 1:30 pm	Python File	5 KB
 gdslib.dll	5/25/2021 9:14 pm	应用程序扩展	932 KB

```
1 {  
2     "CreatViaGroupLayersReg": ".*via.*",  
3     "fixedSmallLayerGap": 0.00500000000000000001,  
4     "defaultDF": 0.02,  
5     "ignorLayersReg": "ctm|cbm|air",  
6     "useDefaultDF": false,  
7     "sheetLayerThreshold": 0.0015,  
8     "dkDeviationThreshold": "10%",  
9     "thinDielectricThreshold": 0.100000000000000001,  
10    "useSheetLayer": true,  
11    "simplifyIgnoreLayersReg": ".*tsv.*"  
12 }
```

gds2xml.json

Configuration字段配置 (JSON文件)

thinDielectricThreshold, dkDeviationThreshold字段, 控制MergeThinLayer的行为:

	thinDielectricThreshold	dkDeviationThreshold	Note
1	0.1	0.1	Merge when layer thickness<0.1um, or 2 layers dk difference less than 10%
2	0.05	-1	Only merge when layer thickness<0.05um
3	-1	0.05	Only merge when 2 layers dk difference less than 5%

useSheetLayer, sheetLayerThreshold字段, 控制是否使用SheetLayer提示求解效率:

	default	Note
useSheetLayer	true	true: use SheetLayer, false: not use
sheetLayerThreshold	0.0015	Default value is <0.0015um will use SheetLayer if useSheetLayer is true. The unit is "um"